

AlGaAs/GaAs Heterojunction Bipolar Transistors with 4W/mm Power Density at X-Band

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Fabrication and microwave characterization of X-band AlGaAs/GaAs heterojunction bipolar transistors are described. MBE was used to prepare the device structure with heavily doped (1×10^{19} /cm³) 1000 Å thick base layers. Two 2 μm x 10 μm emitter fingers separated by 2 μm (total emitter periphery of 40 μm) were used in a self-aligned emitter-base configuration. From the S-parameter measurements $f_{\text{sub } t/}$ and $f_{\text{sub } \text{max}/}$ values of 25 and 20 GHz respectively were determined. Devices operating under CW conditions produced 80 mW CW output power (2W/mm of emitter periphery) with 4 dB gain and 23% power added efficiency at 10 GHz. Under 0.25 μs pulses, 160 mW output power (4 W/mm) was obtained with 4 dB gain and 35% power added efficiency.

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